	Application No.	Applicant(s)	ANI
	10/698,184	GASNER ET AL.	((((((((((((((((((((
Notice of Allowability	Examiner	Art Unit	
	Hsien-ming Lee	2823	
The MAILING DATE of this communication apperature All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIOF the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in or other appropriate commu GHTS. This application is s	this application. If not included inication will be mailed in due cou	rse. THIS
1. This communication is responsive to 8/24/05 & 9/15/05.			
2. X The allowed claim(s) is/are 39-56,58-63,66,67 and 85-102.			
 Acknowledgment is made of a claim for foreign priority una)	been received. been received in Applicatio	n No	from the
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	of this communication to file IENT of this application.	a reply complying with the require	ements
 A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give 	itted. Note the attached EXA es reason(s) why the oath or	AMINER'S AMENDMENT or NOT declaration is deficient.	ICE OF
5. CORRECTED DRAWINGS (as "replacement sheets") mus	st be submitted.		
(a) including changes required by the Notice of Draftspers	on's Patent Drawing Review	v (PTO-948) attached	
1) 🗌 hereto or 2) 🔲 to Paper No./Mail Date			
(b) ☐ including changes required by the attached Examiner's Paper No./Mail Date			
Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in t	.84(c)) should be written on the header according to 37 CF	ne drawings in the front (not the back R 1.121(d).	ck) of
DEPOSIT OF and/or INFORMATION about the depo attached Examiner's comment regarding REQUIREMENT	SIT OF BIOLOGICAL MATE FOR THE DEPOSIT OF BIO	ERIAL must be submitted. Note DLOGICAL MATERIAL.	e the
Attachment(s)	5 □ Notice of In	formal Patent Application (PTO-1	52)
 Notice of References Cited (PTO-892) Dotice of Draftperson's Patent Drawing Review (PTO-948) 	<u> </u>	normal Patent Application (P10-1)	<i>52)</i>
	_ Paper No./	/Mail Date	
 Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date 	08), 7. ⊠ Examiner's	Amendment/Comment	
4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	8. 🛭 Examiner's	Statement of Reasons for Allowa	nce
of blological Waterial	9. 🗌 Other		
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		·	9/29/05

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DETAILED ACTION

Remarks

- 1. Applicant's arguments filed 8/24/2005 and 9/15/2005 are persuasive. The Final rejection has withdrawn.
- 2. Applicant's cancellation to claims 1-38, 57, 64, 65 and 68-84 is acknowledged. Claims 39-56, 58-63, 66, 67 and 85-102 are pending in the application.

Examiner's Amendment

3. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Scott V. Lundberg (Reg. No. 41,958) on Sep. 29, 2005.

4. The application has been amended as follows:

(note) please refer to the amendment filed on Sep. 15, 2005 for the following changes.

In claim 85, at line 5, insert – intermediate – before "conductive"; at line 6, replace "layers" with – layer --; at line 10, delete "one of more"; at line 11, replace "layers" with – layer--; at line 11, delete "one or more"; and at line 12, replace "layers" with – layer --.

In claim 86, at line 2, delete "one from" and replace "comprising" with -consisting of --.

In claim 87, at line 2, delete "one of" after "forming"; and at line 4, replace "insulation" with - insulating material --.

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In claim 88, at line 2, delete "an" after "gaps" and delete "one of " after "in"; and at line 3, delete "the one of " after "through."

In claim 89, at line 1, delete "the one of."

In claim 95, at line 6, replace "intermediate conductive layer" with – or more intermediate conductive layers --. (Emphasis added)

In claim 95, at lines 8-9, replace the entire paragraph of "forming at least one layer of insulating material separating the at least one conductive layers from each other; and "with the following paragraph -- forming at least one layer of insulating material between the top conductive layer and an intermediate conductive layer closest the top conductive layer of the one or more intermediate conductive layers and between layers of the more intermediate conductive layers, wherein the top conductive layer and every one of the more intermediate conductive layers are separated from each other by a layer of insulating material; and --.

In claim 95, at line 10, replace "one of the at least one intermediate conductive layers" with -- the one intermediate conductive layer --.

In claim 95, at lines 11-12, replace "the at least one intermediate conductive layers" after "of" with -- the one or more intermediate conductive layers --.

In claim 95, at line 13, delete "one of the at least" before "intermediate."

In claim 95, at line 14, replace "at least one "before "intermediate" with – one or more

In claim 96, at lines 1-2, replace "the one of the at least one intermediate conductive layer "with -- the intermediate conductive layer --.

In claim 97, at line 2, delete "one of" after "and."

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In claim 97, at line 3, delete "the one of" after "separating."

In claim 98, at line 2, replace "one of the at least one layers" with – the at least one layer

In claim 98, at line 3, replace "an intermediate" with – the intermediate --.

In claim 98, at line 4, replace "the remaining at least one layers of insulation" with – remaining layers of insulating material between layers of the more intermediate conductive layers --.

Allowable Subject Matter

- 5. Claims 39-56, 58-63, 66, 67 and 85-102 are allowed.
- 6. The following is an examiner's statement of reasons for allowance:

The prior art of record at least neither teaches nor suggests the gaps take up no more than 10% of the total area of the first metal layer under the bond pad; patterning the first metal layer to form gaps, wherein the gap extend in a current flow direction; the relatively stiff material is TiN or is TiW; at least one sub-layer of material that is relatively stiff is adapted to prevent the cracking of the one intermediate conductive layer; and forming gaps in one of the one intermediate conductive layer closest the top conductive layer, the gaps being adapted to prevent cracking of the one intermediate conductive layers by forming pillars of relatively stiff insulation material passing through the one of the one intermediate conductive layers closest the top conductive layer.

7. Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue

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fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

8. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Hsien-ming Lee whose telephone number is 571-272-1863. The examiner can normally be reached on Tuesday-Thursday ($7:30 \sim 6:00$).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Matthew Smith can be reached on 571-272-1907. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Hsien-ming Lee Primary Examiner Art Unit 2823

Sep. 29, 2005

HSIEN-MING LEE /)
PRIMARY EXAMINER